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APPLICATION NO).	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/537,868		06/07/2005	Yoshiaki Hasegawa	OKUDP0116US	8395
51921	7590	10/02/2006		EXAMINER	
		LINO (MEI)	INGHAM, JOHN C		
RENNER, OTTO, BOISSELLE & SKLAR, LLP 1621 EUCLID AVENUE			·	ART UNIT	PAPER NUMBER
19TH FLC	OR		2814		
CLEVELA	ND, OF	H 44115	DATE MAILED: 10/02/2006		

Please find below and/or attached an Office communication concerning this application or proceeding.

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	Application No.	Applicant(s)	VI
	10/537,868	HASEGAWA ET AL.	
Office Action Summary	Examiner	Art Unit	
	John C. Ingham	2814	
The MAILING DATE of this communication a	opears on the cover sheet with	the correspondence address	
Period for Reply			
A SHORTENED STATUTORY PERIOD FOR REP WHICHEVER IS LONGER, FROM THE MAILING I - Extensions of time may be available under the provisions of 37 CFR 1 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory perior - Failure to reply within the set or extended period for reply will, by statu. Any reply received by the Office later than three months after the mail earned patent term adjustment. See 37 CFR 1.704(b).	DATE OF THIS COMMUNICA: .136(a). In no event, however, may a reply d will apply and will expire SIX (6) MONTHS tte, cause the application to become ABANI	TION. be timely filed from the mailing date of this communication DONED (35 U.S.C. § 133).	
Status			
1)⊠ Responsive to communication(s) filed on <u>07</u>	June 2005		
· _ · · ·	is action is non-final.		
3) Since this application is in condition for allow		prosecution as to the merits is	
closed in accordance with the practice under	•	·	
Disposition of Claims			
4) Claim(s) 1-19 is/are pending in the applicatio	n.		
4a) Of the above claim(s) is/are withdra	awn from consideration.		
5) Claim(s) is/are allowed.			
6)⊠ Claim(s) <u>1-19</u> is/are rejected.			
7) Claim(s) is/are objected to.			
8) Claim(s) are subject to restriction and	or election requirement.		
Application Papers			
9) ☐ The specification is objected to by the Examir	ner.		
10)⊠ The drawing(s) filed on <u>07 June 2005</u> is/are:	a)⊠ accepted or b)⊡ objecte	d to by the Examiner.	
Applicant may not request that any objection to the	e drawing(s) be held in abeyance.	See 37 CFR 1.85(a).	
Replacement drawing sheet(s) including the corre	ction is required if the drawing(s)	is objected to. See 37 CFR 1.121(d).
11) The oath or declaration is objected to by the E	Examiner. Note the attached O	ffice Action or form PTO-152.	
Priority under 35 U.S.C. § 119			
12)⊠ Acknowledgment is made of a claim for foreig	in priority under 35 H.S.C. & 11	19(a)-(d) or (f)	
a)⊠ All b) Some * c) None of:		3(a)-(d) 01 (l).	
1.⊠ Certified copies of the priority documer			
2. Certified copies of the priority documer	• • •		
 Copies of the certified copies of the pri application from the International Bures 	·	eived in this National Stage	
* See the attached detailed Office action for a lis	st of the certified copies not rec	eived.	
Attachment(s)			
1) D Notice of References Cited (PTO-892)	4) Interview Sum		
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)		ail Date mal Patent Application	
3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 6/7/05.5/25/06.	6) Other:		

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims **1-11** are rejected under 35 U.S.C. 102(b) as being anticipated by Goto (US 6,522,676).
- 3. Regarding claims **1** and **7**, Goto discloses in Fig 6 a semiconductor light-emitting element comprising: a first group II-V compound semiconductor (5a); a current confining layer (6), which is made of a second group III-V compound semiconductor that has grown on a selected surface area of the first group III-V compound semiconductor and which has a striped opening (see Fig 1) extending along the length of a resonant cavity; and a third group III-V compound semiconductor (5b), which covers the surface of the first group III-V compound semiconductor that is exposed through the striped opening and the surface of the current confining layer, and wherein the group III-V compound semiconductors are gallium nitride based (col 8 ln 10-17).
- 4. Regarding claims **2-5**, Goto discloses in Fig 6 the element of claim 1 wherein the current confining layer (6) has two overhanging portions (above area 52) that overhang toward the striped opening, wherein a gap (filled by 52) is provided between each of the two overhanging portions of the current confining layer and a part of the surface of the first group III-V compound semiconductor (5a), wherein the gap has a height of 0.1µm

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and a width of 0.5µm (col 8 In 46-51) and wherein a portion of the third group III-V compound semiconductor (5b), which contacts with the surface of the first group III-V compound semiconductor through the striped opening has a width of 2.5µm (W2).

- 5. Regarding claim **6**, Goto discloses in Fig 6 the element of claim 1 wherein the first group III-V compound semiconductor has a multilayer structure (3, 4, 5a) including an active layer (4).
- 6. Regarding claim **8**, Goto discloses in Fig 6 the element of claim 7 wherein the current confining layer (6) is AlGaN and has a thickness of 0.3μm (col 8 ln 16, 30).
- 7. Regarding claims **9-11**, Goto discloses in Fig 6 the element of claim 1 wherein the conductivity of the first (5a) and third (5b) group III-V compound semiconductors is the same (p type), and wherein the conductivity of the second group III-V compound semiconductor is opposite (n type).
- 8. Regarding claim **12**, **16** and **18**, Goto discloses in Fig 8 a method for fabricating a semiconductor light-emitting element, the method comprising the steps of: (step a) providing a striped masking layer (15), with a width set to 2.5µm, on a first Group III-V compound semiconductor (56a); selectively growing a second Group III-V compound semiconductor (6) over the entire surface of the first group III-V compound semiconductor except a portion covered with the masking layer, thereby forming a current confining layer that has a striped opening defined by the masking layer (step b); selectively removing the masking layer; and growing a third Group III-V compound semiconductor (56b), to cover the surface of the first group III-V compound semiconductor, which is exposed through the striped opening at a portion with a width

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of 2µm, and the surface of the current confining layer (step c), and wherein the group III-V compound semiconductors are gallium nitride based (col 8 ln 10-17).

- 9. Regarding claim **13**, Goto discloses in Fig 8(b) the method of claim 12 wherein the step of selectively growing a second group III-V compound semiconductor (6) includes growing laterally toward the center of the masking layer, thereby defining two overhanging portions for the current confining layer (col 9 ln 7-17).
- 10. Regarding claim **14**, Goto discloses in Fig 8(c) the method of claim 13 wherein the removal of the masking layer includes removing parts of the masking layer (15), which are located under the overhanging portions of the current confining layer (6), thereby making the overhanging portions (area 52) overhang toward the center of the striped opening.
- 11. Regarding claim **15**, Goto discloses in Fig 8(c) the method of claim 14, wherein the growing of the third group III-V compound semiconductor includes providing gaps between the first group III-V compound semiconductor (56a) and the overhanging portions (portions of 6 above areas 52).
- 12. Regarding claim **17**, Goto discloses in Fig 6 the element of claim 1 wherein the first group III-V compound semiconductor has a multilayer structure (3, 4, 5a) including an active layer (4).
- 13. Regarding claim **8**, Goto discloses in Fig 6 the element of claim 7 wherein the current confining layer (6) is AlGaN and has a thickness of 0.3µm (col 8 ln 16, 30).

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Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to John C. Ingham whose telephone number is (571) 272-8793. The examiner can normally be reached on M-F, 8am-5pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

John C Ingham Examiner Art Unit 2814

jci

HOWARD WEISS PRIMARY EXAMINER

Dud Mh